

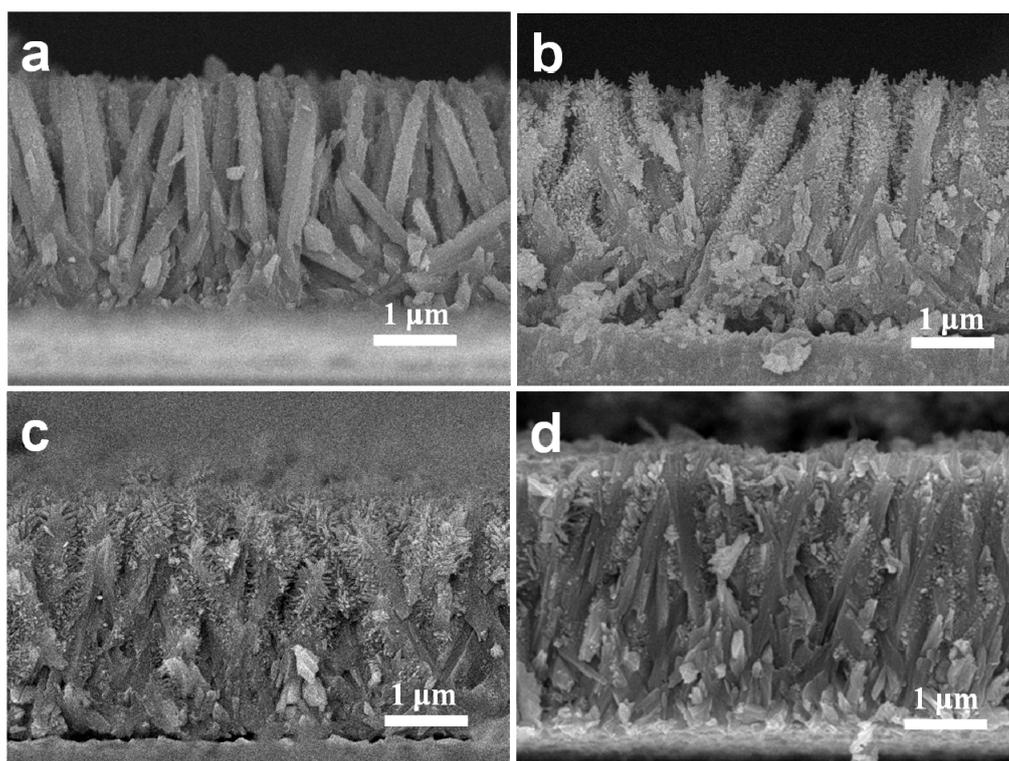
## Electronic Supplementary Information

### Wet Chemical Route to Hierarchical TiO<sub>2</sub> Nanodendrite/Nanoparticle Composite

#### Anodes for Dye-Sensitized Solar Cells

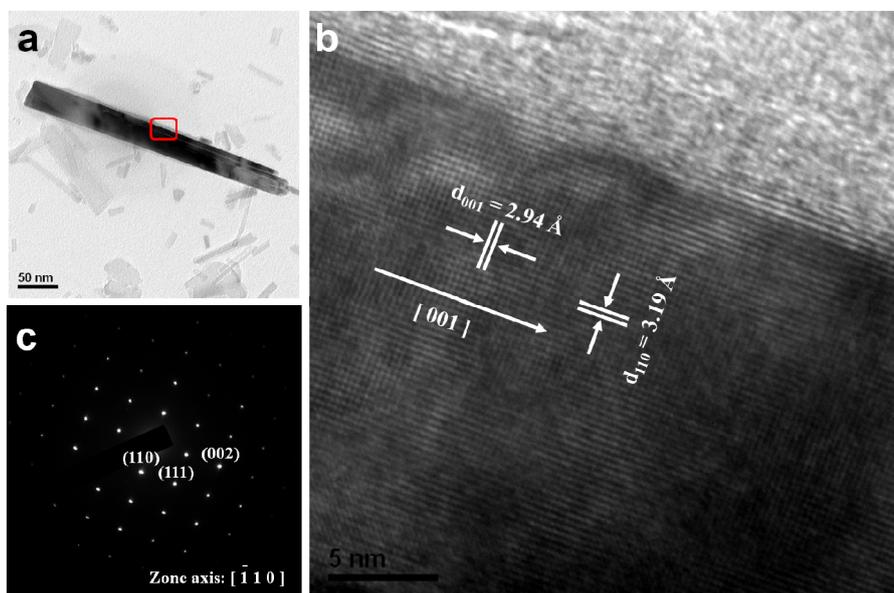
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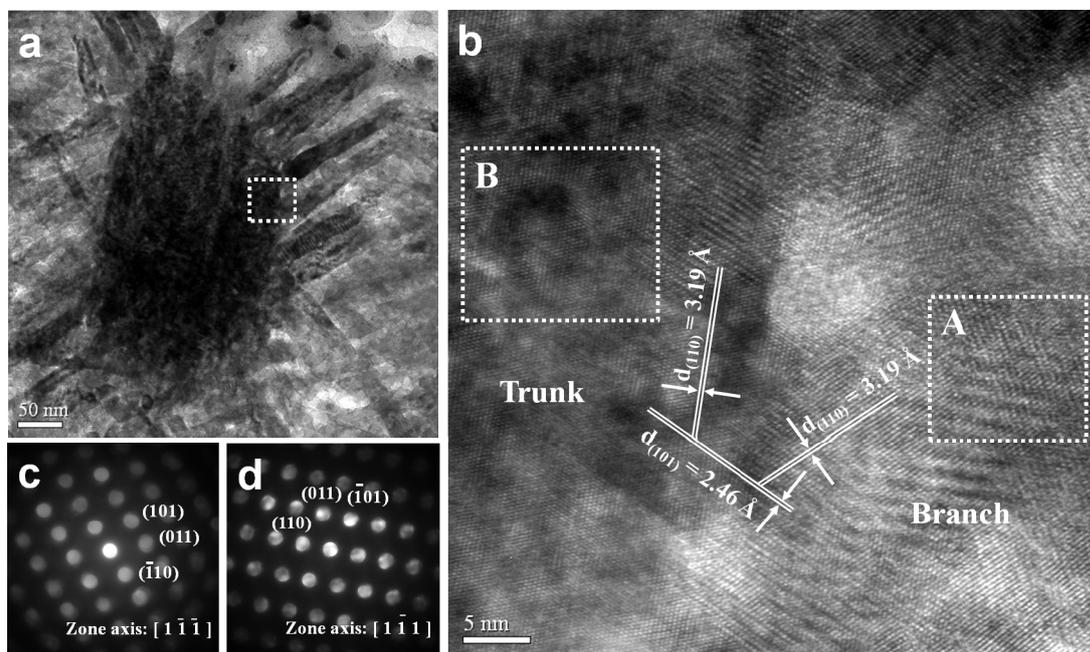


**Figure S1.** SEM images of the ND arrays formed for various branch growth periods.

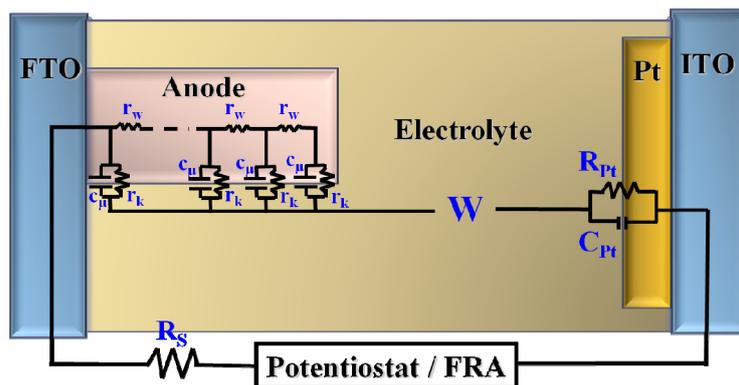
(a) 0 h; (b) 1.5 h; (c) 2 h and (d) 2.5 h.



**Figure S2.** (a) Typical cross-sectional TEM image of an individual NW. (b) HRTEM image and (c) the corresponding SAED pattern of NW.



**Figure S3.** (a) TEM image of the TiO<sub>2</sub> ND/NP film. (b) HRTEM of the interfacial region of the trunk and branch in the ND/NP film denoted in (a). (c) and (d) Diffraction patterns taken from the portions of the branch (square A) and trunk (square B) in (b).



**Figure S4.** Suggested equivalent circuit of the DSSCs.  $R_w (= r_w \times L)$  is the electron transport resistance in the anode ( $L$  is the thickness of the anode),  $R_k (= r_k/L)$  is the charge transfer resistance related to recombination of an electron at the interface,  $C_\mu (= c_\mu \times L)$  is the chemical capacitance,  $R_s$  is a lumped series resistance for the transport resistance of FTO and all resistances out of the cell,  $W$  is the impedance of diffusion of the redox species in the electrolyte, and  $R_{Pt}$  and  $C_{Pt}$  are the charge transfer resistance and the interfacial capacitance at the counter electrode/electrolyte interface, respectively.